



Simulation of CMOS Compatible Sensor Structures for Dielectrophoretic Biomolecule Immobilization

IHP - Frankfurt (Oder) - Germany

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**COMSOL
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Theory and use of COMSOL Multiphysics

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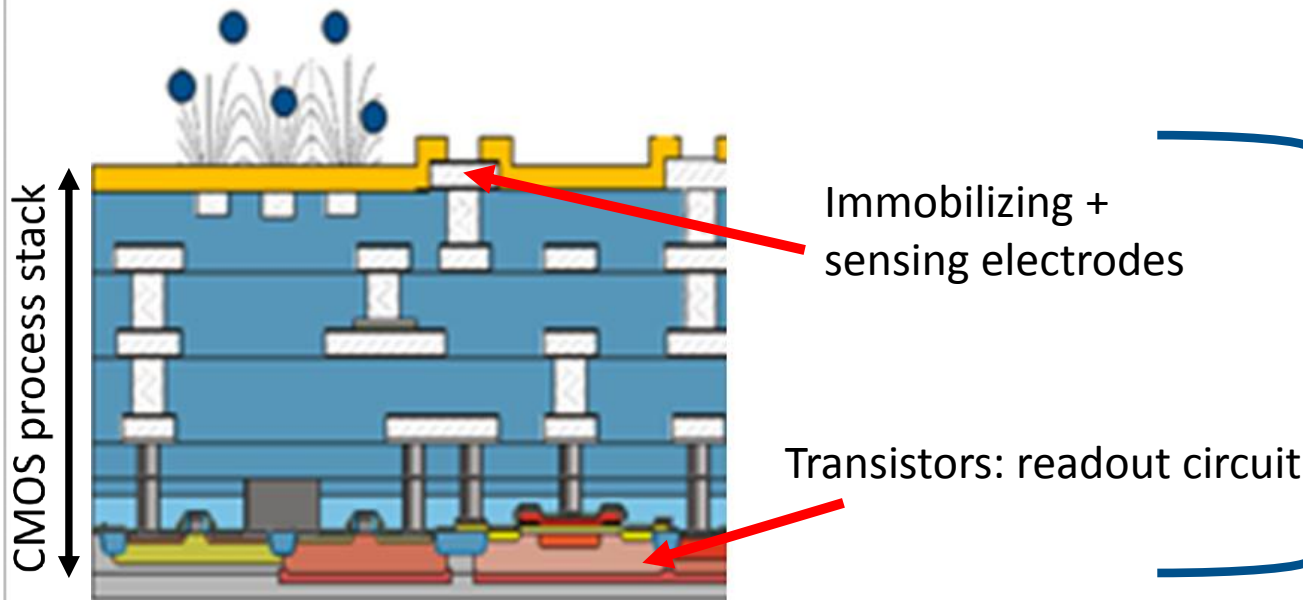
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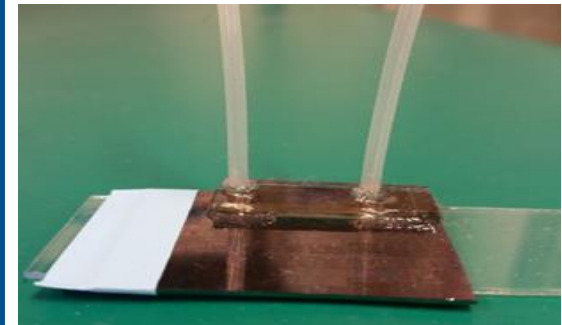
Introduction

Development of a lab-on-chip device for virus immobilization and detection

- ❑ Electrical immobilization of viruses on immobilizing electrodes -> Dielectrophoresis
- ❑ Sensing and analysis of the immobilized viruses -> All electrical biosensor
- ❑ Silicon microelectronics compatible -> operating in CMOS/BiCMOS technology



Single chip: immobilization and sensing



Target : To establish RF biosensors for immobilizing and sensing

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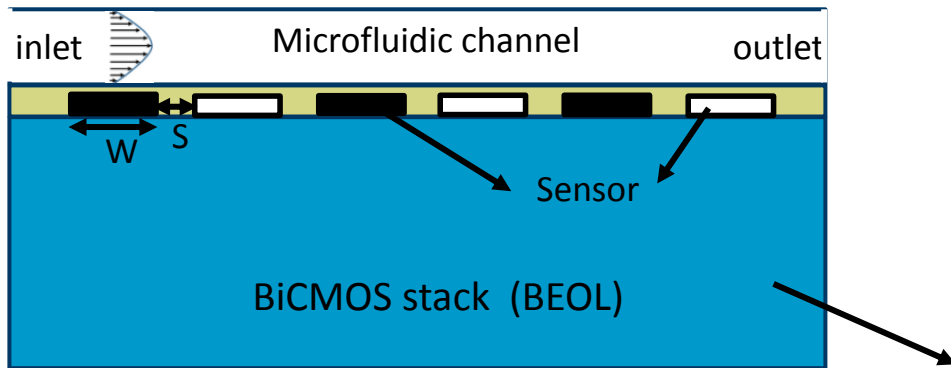
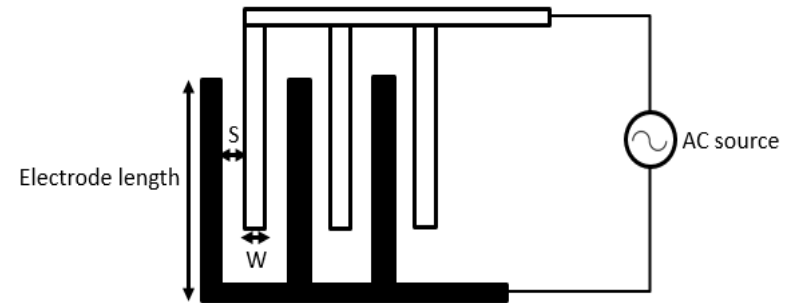
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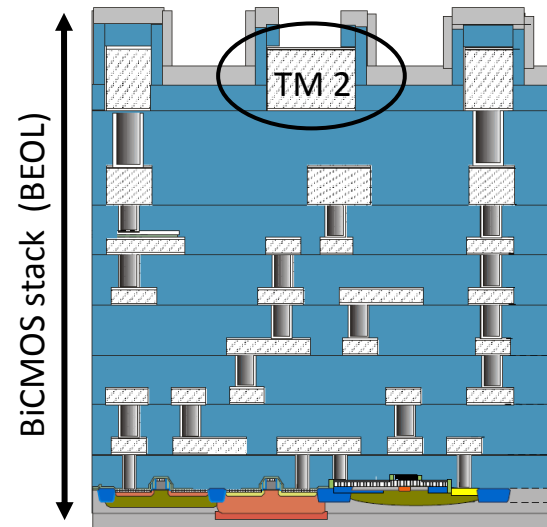
Theory: electrode structure

Established electrode structure for RF sensing

- ❑ Interdigitated electrodes (IDE) -> used as sensor
- ❑ Same electrode structure -> used for immobilizing of viruses



Cross-sectional view of electrode structure with microfluidic channel



Theory: Dielectrophoresis (DEP) principles

Dielectrophoresis -> electrical immobilization of particles

- ❑ Non Uniform electric field effect on particles
- ❑ Dependent on -> permittivity, conductivity, particle size and electric field

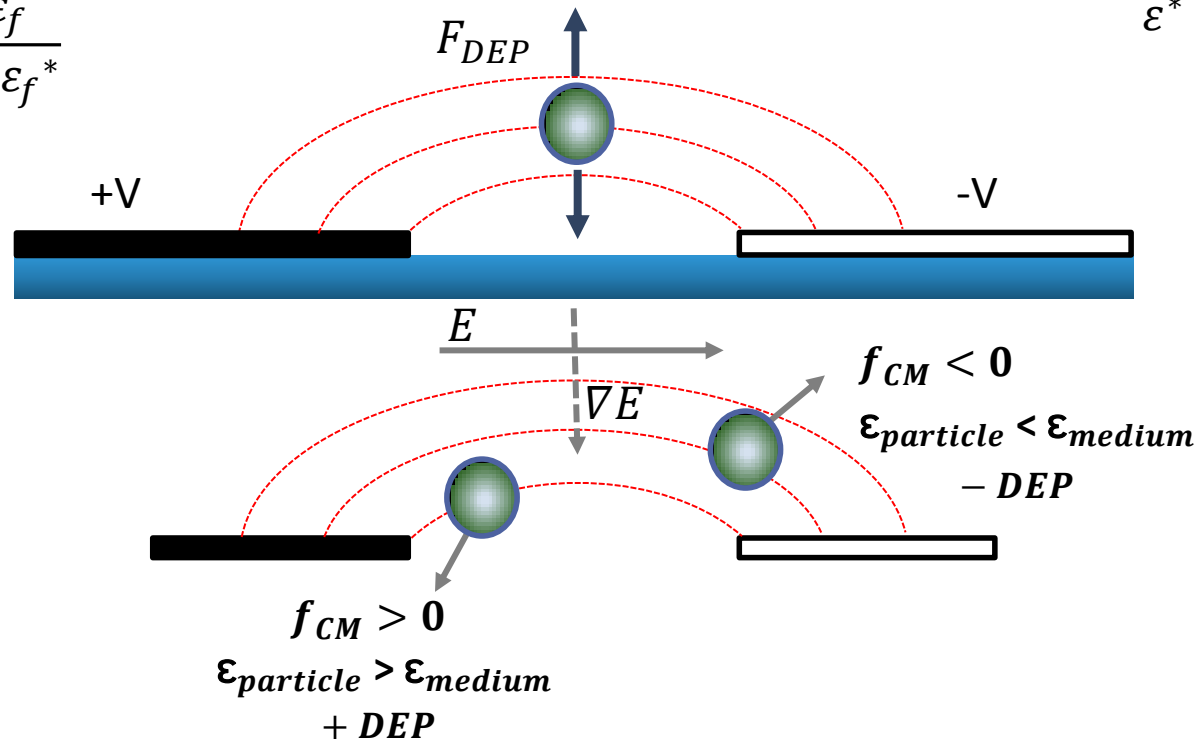
Clausius-Mosotti factor

$$f_{CM} = \frac{\epsilon_p^* - \epsilon_f^*}{\epsilon_p^* + 2\epsilon_f^*}$$

$$F_{DEP} = 2\pi r_p^3 \epsilon_f \text{Re}(f_{CM}) \nabla |E|^2$$

Complex permittivity

$$\epsilon^* = \epsilon - j \frac{\sigma}{\omega}$$



Use of Comsol Multiphysics (version 5.3)

Multiphysics tool COMSOL is used -> immobilization analysis

Three modules used : Electric current, fluid flow, particle tracing

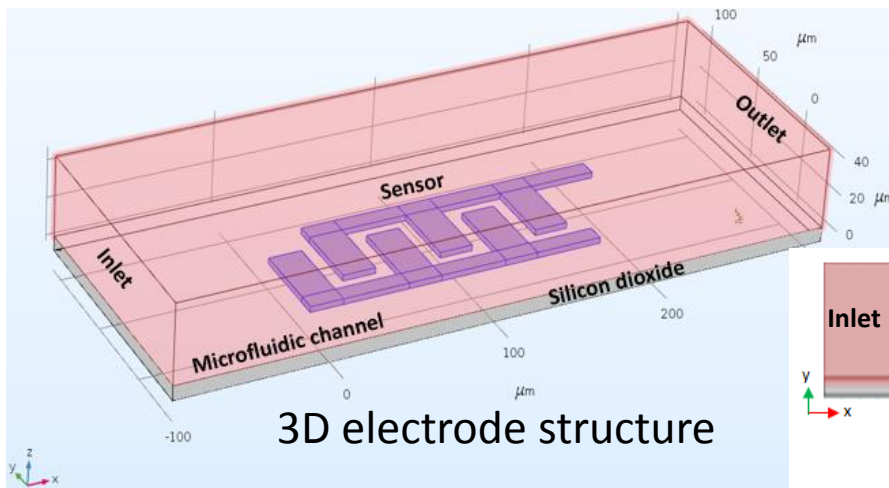
Governing equations:

Electric field : $E = -\nabla V$

Fluid flow : $0 = \nabla \cdot \left[-pl + \mu(\nabla u + (\nabla u)T) - \frac{2}{3} \mu (\nabla \cdot u)l \right] + F$

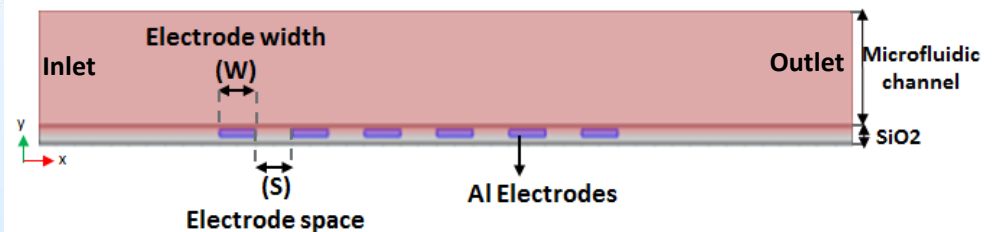
Drag Force: $F_{Drag} = \left(\frac{1}{T_p} \right) \cdot m_p(u - v)$

Dielectrophoresis : $F_{DEP} = 2\pi r_p^3 \epsilon_f Re(f_{CM}) \nabla |E|^2$



3D electrode structure

2D electrode structure



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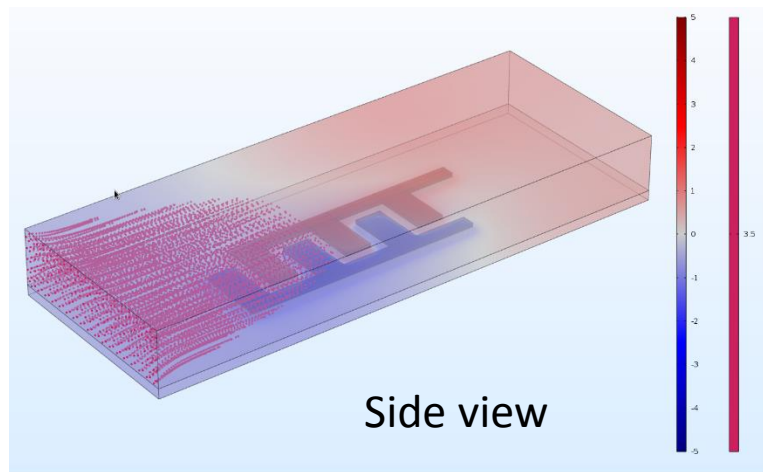
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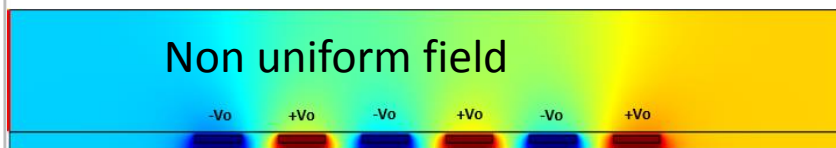
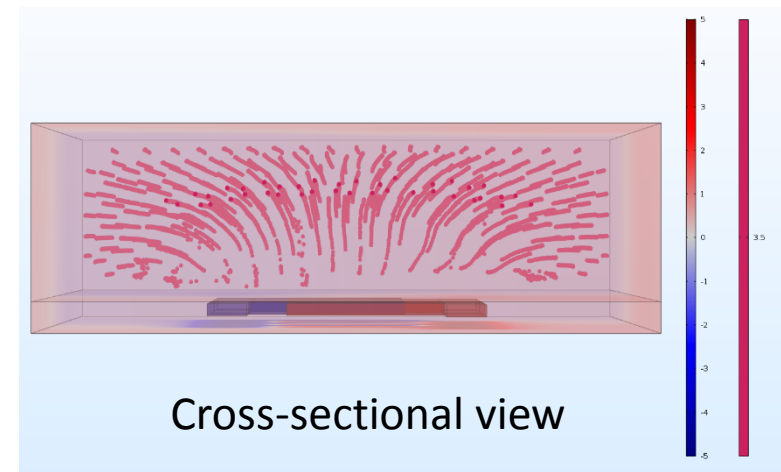
Generation of non-uniform electric field gradient using IDE

- ❑ Positive DEP for applied voltage: particles are attracted
- ❑ Tuning parameters: voltage, flow-velocity, IDE geometry

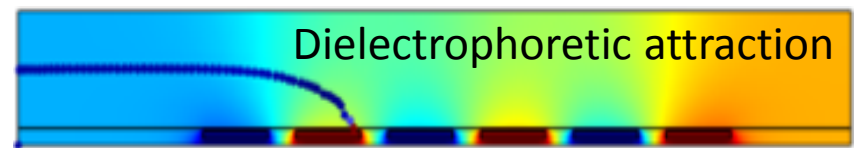
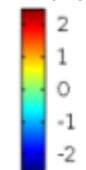
Spatial variation of the electric potential in the microfluidic channel



Particle trajectory influenced by DEP force

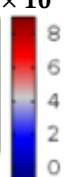


V (V)



F (N)

$\times 10^{-12}$



Simulation studies were all done in 2D to reduce the computational time

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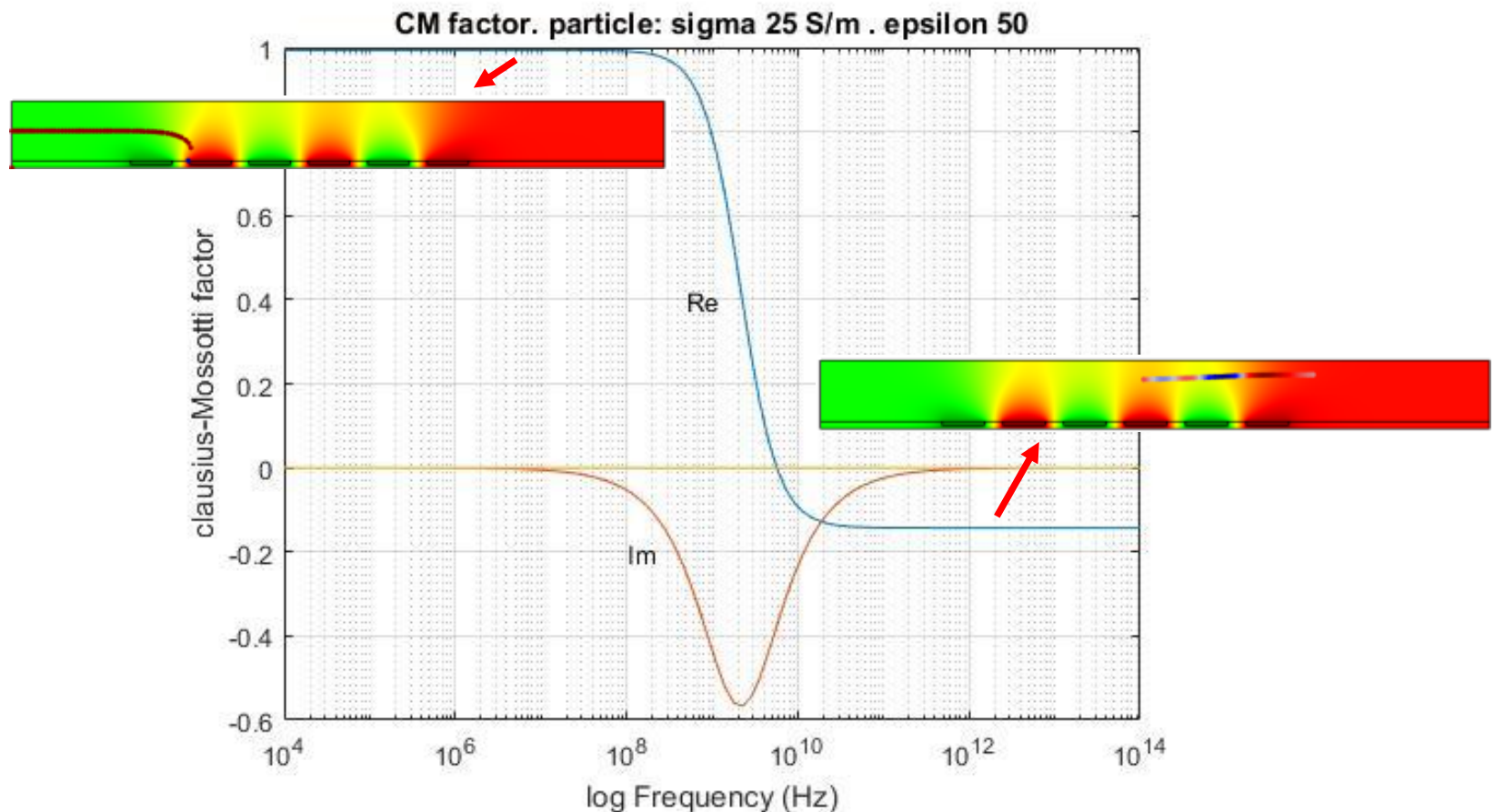
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Results: Clausius-Mosotti factor

Clausius-Mosotti factor -> function of permittivity & conductivity

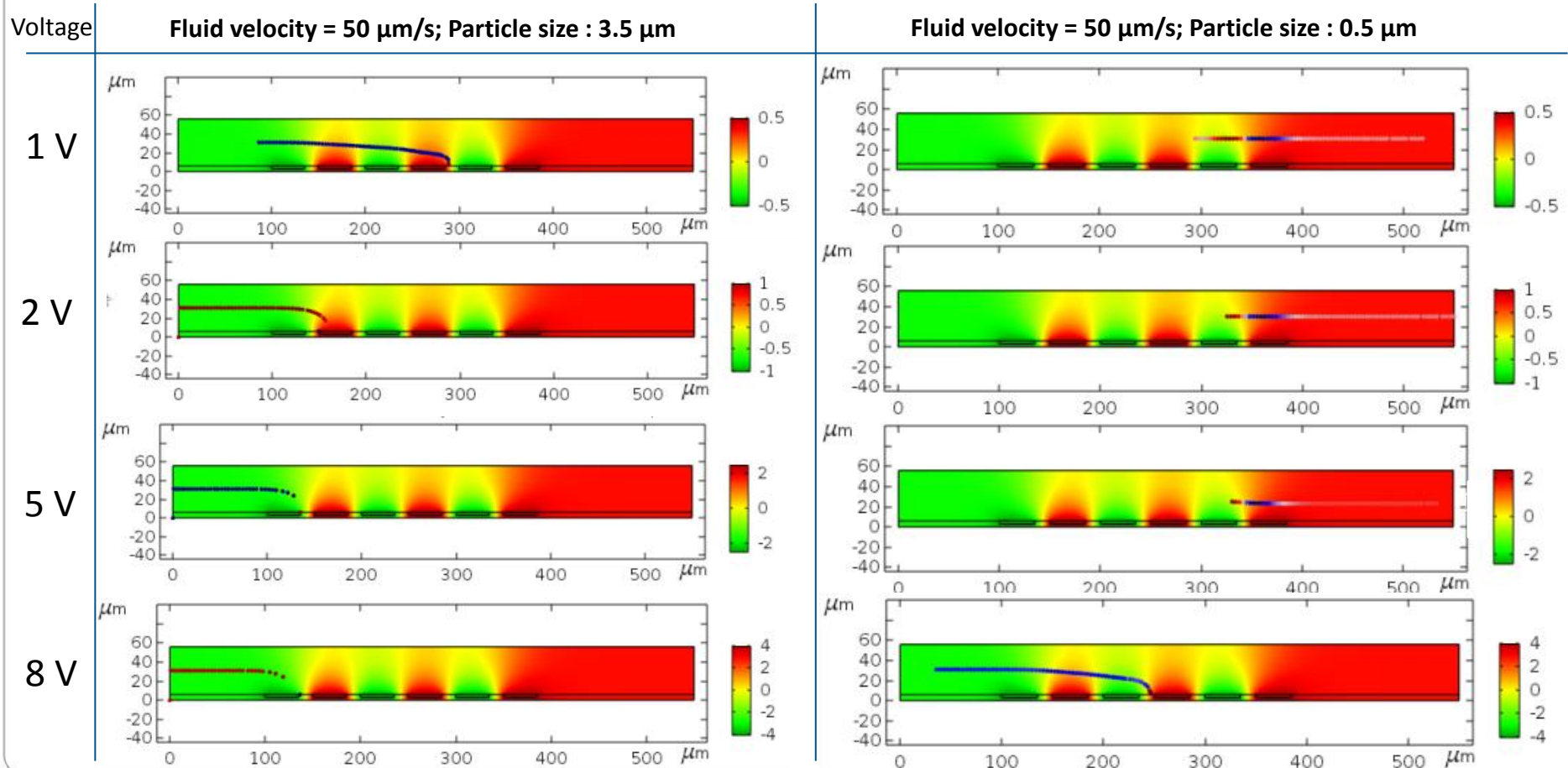
- ❑ Frequency dependent parameter : positive and negative dielectrophoresis
- ❑ Choice of operating frequency -> for positive dielectrophoresis



Results: Influence of voltage

The applied voltage influences the particle attraction

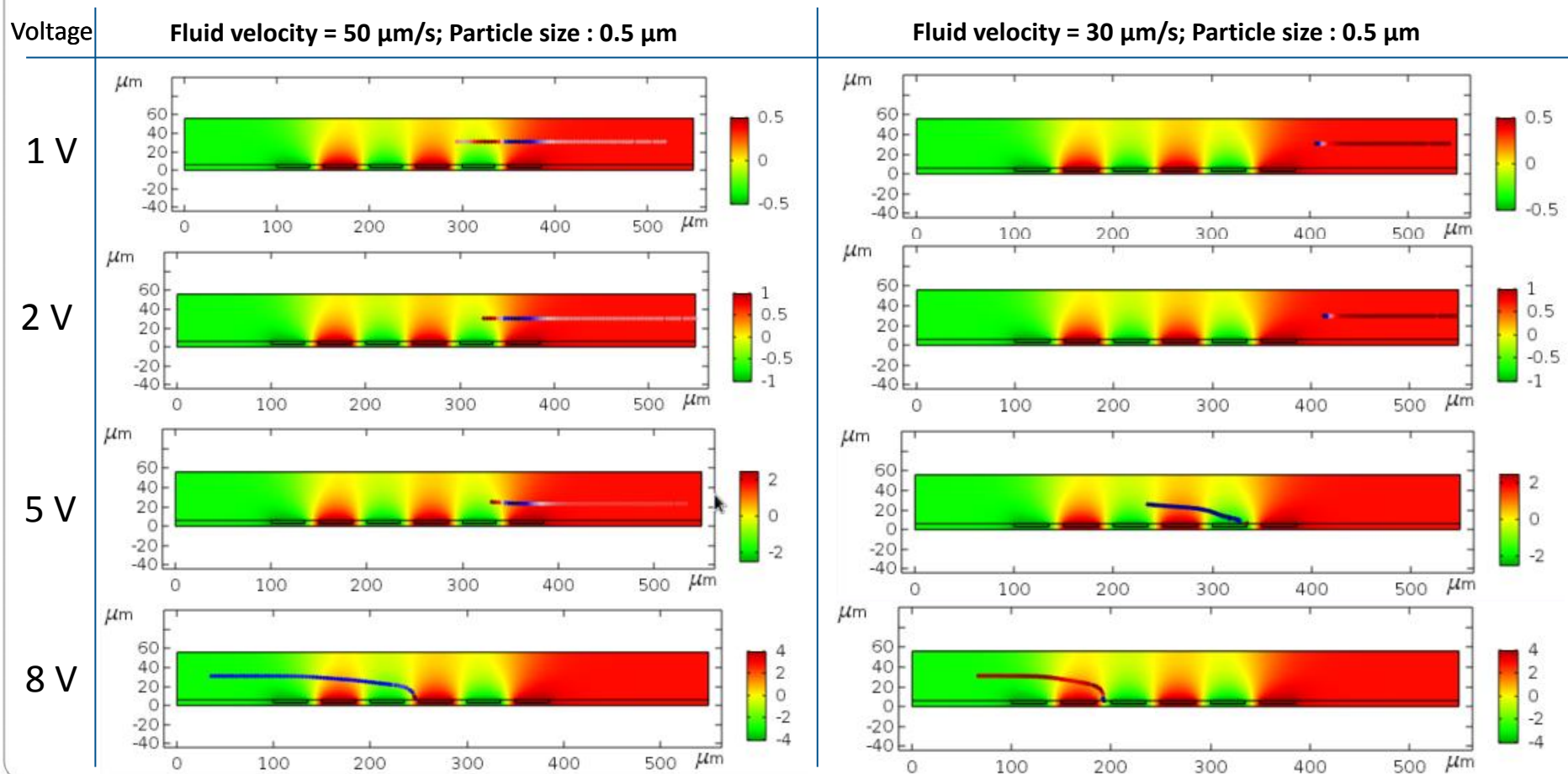
- Dependent on the size of the particle
- Smaller particles require higher voltage with the same fluid velocity



Results : Influence of fluid velocity

The attraction of the particle is dependent on fluid velocity

- ❑ Attraction of the particle takes place when DEP force nullifies the drag force
- ❑ For same voltage, lower fluid velocity aids in better attraction

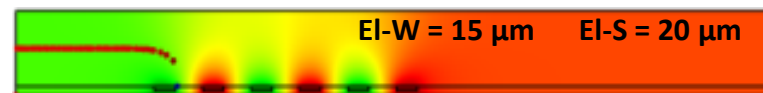
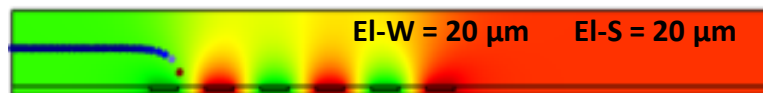
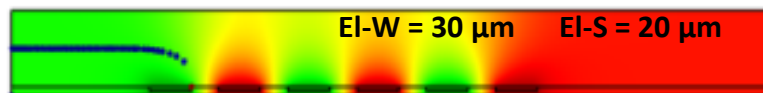
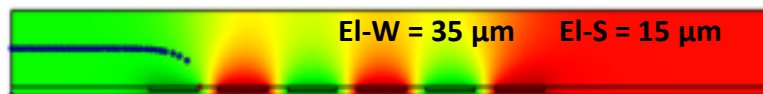


Results: influence of electrode geometry

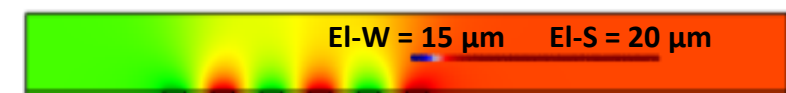
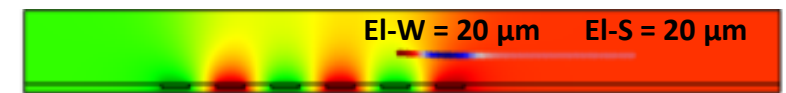
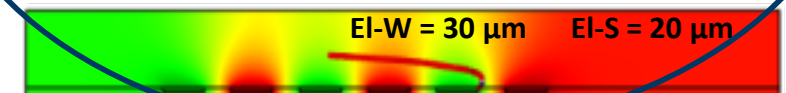
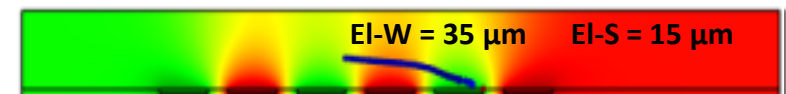
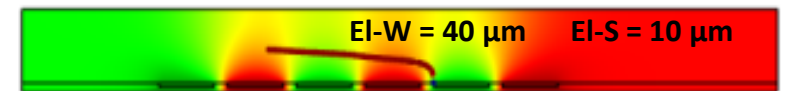
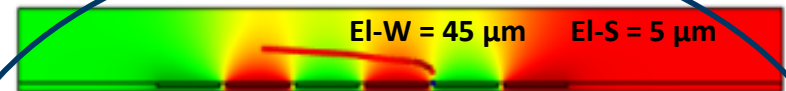
Electrode geometry helps in forming non-uniform electric field

- ❑ Asymmetric geometry : unequal width and spacing of electrode is better
- ❑ Width of electrode > spacing, the influence of non uniform field is higher

Particle-d = 3.5 μm Voltage = 5 V Fluid velocity = 30 $\mu\text{m/s}$



Particle-d = 0.5 μm Voltage = 5 V Fluid velocity = 30 $\mu\text{m/s}$



Conclusion and Acknowledgement

- ❑ Electrode structure which is used for RF sensing can be also be used for immobilization.
- ❑ COMSOL Multiphysics is a useful tool for such for co-simulations.
- ❑ Dielectrophoresis is dependent on the voltage, flow velocity and geometry of the electrode.
- ❑ In CMOS compatible Technology for a given geometry of electrodes the only variation parameter is fluid velocity.



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Thank you for your attention!

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